

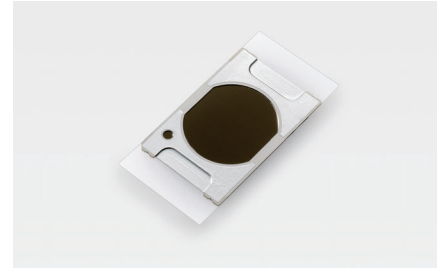
# DIUTHAME-MSI for chemorepellent of slime mold using blotting method

To take MSI(Mass Spectrometry Imaging) of bacteria on culture media by MALDI is very difficult because of the following reasons;

- a) Not allow to set a agar medium sample itself in MS system due to high humidity and large size.
- b) Kill or destroy living samples such as slime mold if a section sample is made
- c) Matrix-derived peaks may interfere in low mass region from bacteria

DIUTHAME blotting method is allowed to obtain MSI without these issues. This paper reports that MS imaging of the slime mold cultured on the agar medium is taken by DIUTHAME.

It is thought that when different kinds of slime mold approaches closely the slime mold excretes chemorepellent to avoid each other and take evasive action. The distribution of the chemorepellent was measured by MS imaging.



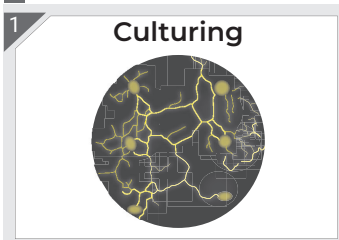
▲ A13331-18-2

## Measurement condition

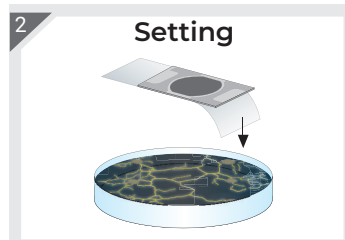
Measurement mode : Positive ion mode

Sample : Chemorepellent of slime mold

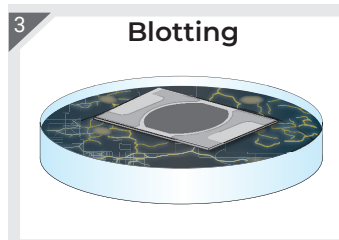
## Method



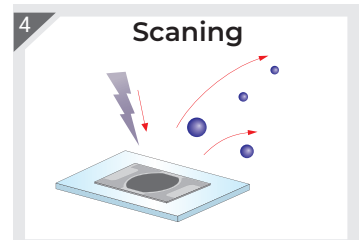
Slime mold was cultured on agar medium.



DIUTHAME was placed on the slime mold cultured on agar medium.



The contained materials on the slime mold were blotted.



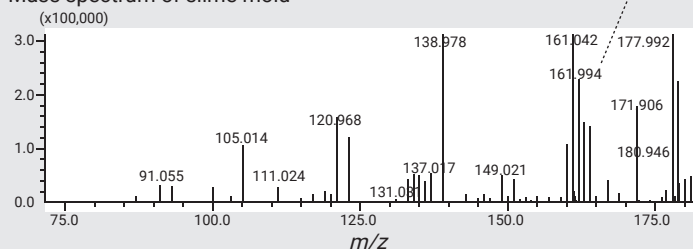
Carefully removed the DIUTHAME from the agar medium. After drying, DIUTHAME was attached on adapter and MS imaging was taken.

## Result

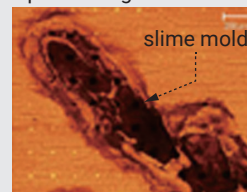
The MS imaging results of a slime mold on agar medium taken by blotting method are shown below.

The distribution of fragment ions of caffeic acid ( $m/z$  162) indicates that caffeic acid is a slime mold chemorepellent. This suggests that the blotting method of DIUTHAME is also effective for MS imaging of the bacteria on the culture medium.

Mass spectrum of slime mold

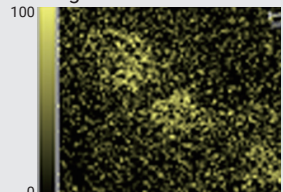


Optical image

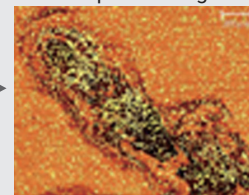


$m/z$  162

Fragment ions of caffeic acid



Composite image



Measurements were carried out in cooperation with Professor Shunsuke Izumi, Graduate School of Integrated Sciences Hiroshima University

Subject to local technical requirements and regulations, availability of products included in this promotional material may vary. Please consult with our sales office! Information furnished by HAMAMATSU is believed to be reliable. However, no responsibility is assumed for possible inaccuracies or omissions. Specifications are subject to change without notice. No patent rights are granted to any of the circuits described herein. ©2020 Hamamatsu Photonics K.K.

**HAMAMATSU PHOTONICS K.K.** [www.hamamatsu.com](http://www.hamamatsu.com)

HAMAMATSU PHOTONICS K.K., Electron Tube Division  
314-5, Shimokanzo, Iwata City, Shizuoka Pref., 438-0193, Japan, Telephone: (81)539/62-5248, Fax: (81)539/62-2205

APR. 2020